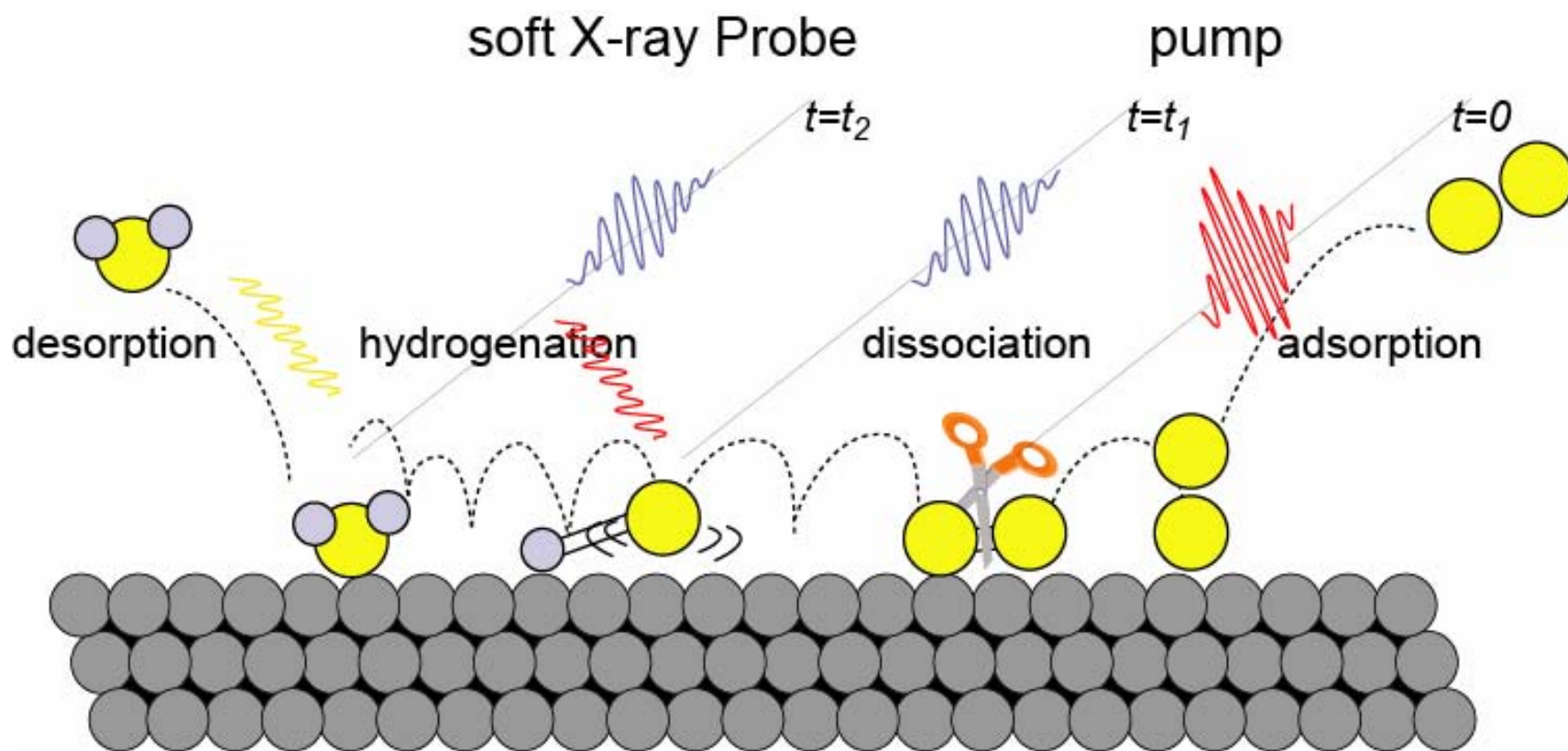


# Coherent Control of Surface Reactions using THz Radiation

**Hirohito Ogasawara Dennis Nordlund and Anders Nilsson,  
Stanford Synchrotron Radiation Laboratory**

- 80% of all important chemical reactions take place on interfaces
- Catalytic processes is the largest chemical industry
- Energy technology, fuel cells, splitting of water by solar
- Environmental science
- Semiconductor technology
- Biosurfaces

# Elementary Surface Reactions

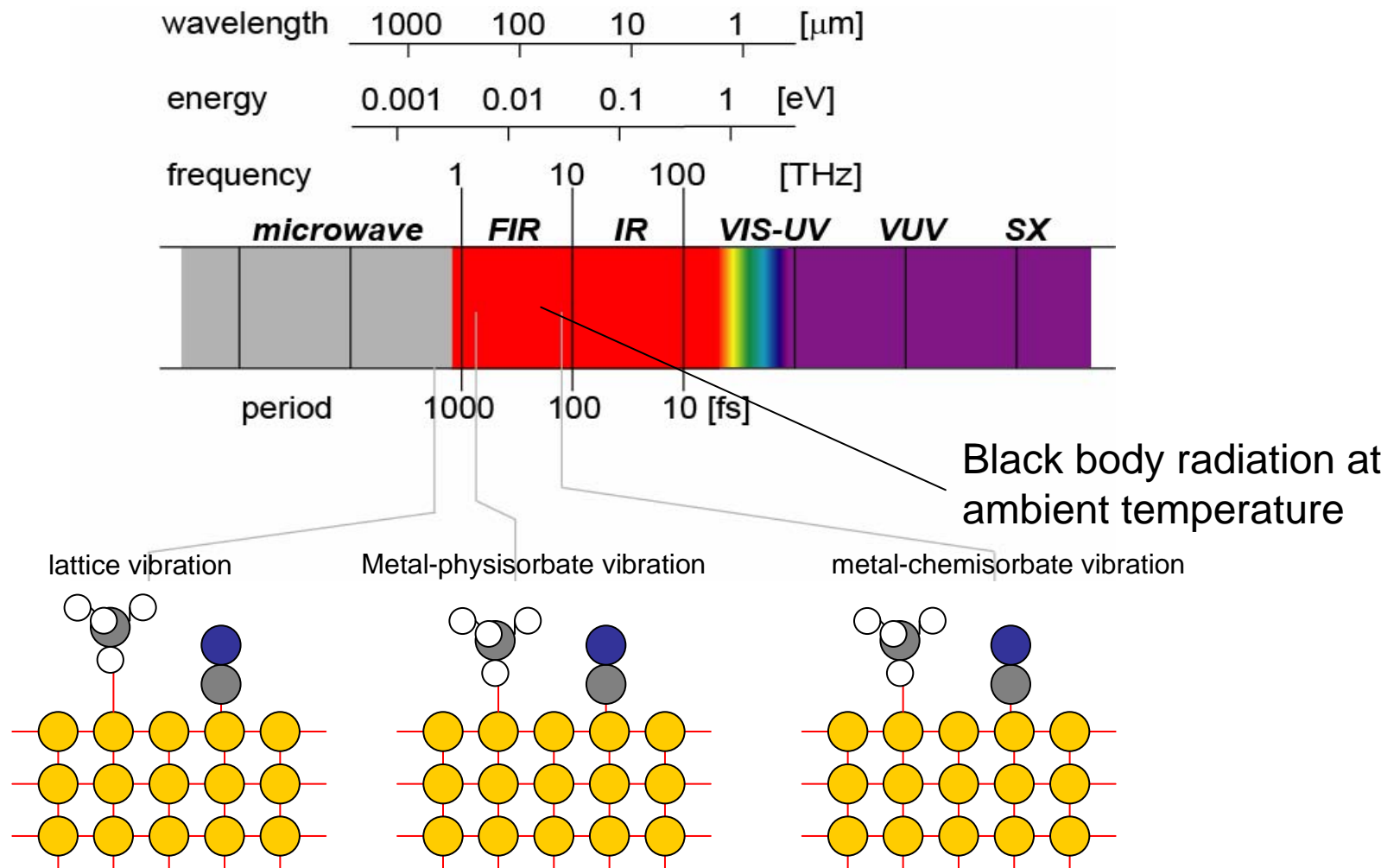


# Challenges for Pump and Probe Experiments

- Most relevant chemical reactions are driven by temperature (kT) not optical excitations
- Synchronization between pump and probe
- Control of reaction coordinate system
- Selective detection of molecules on surfaces, differentiate between species

THz pump and X-ray probe

# THz radiation and molecular vibration

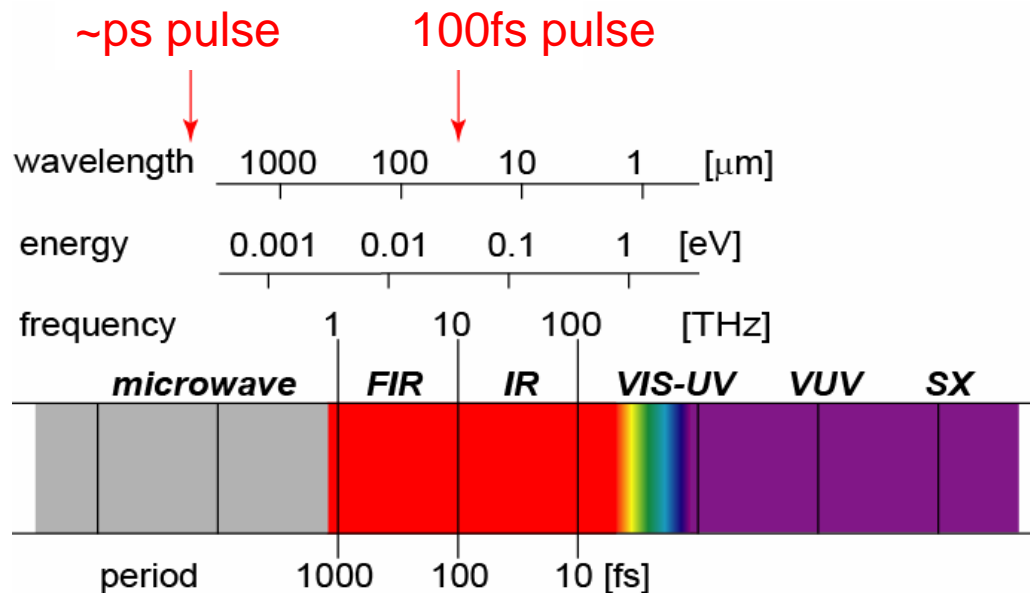
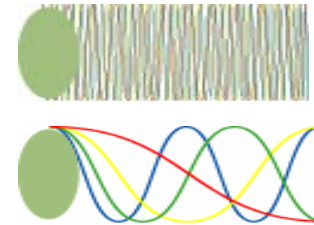


**1-10 THz = Far-IR** ( $\sim 0.01[\text{eV}]$ ,  $\sim 30[\mu\text{m}]$ ) can excite vibrations:  
lattice vibration, adsorbate-metal vibration.

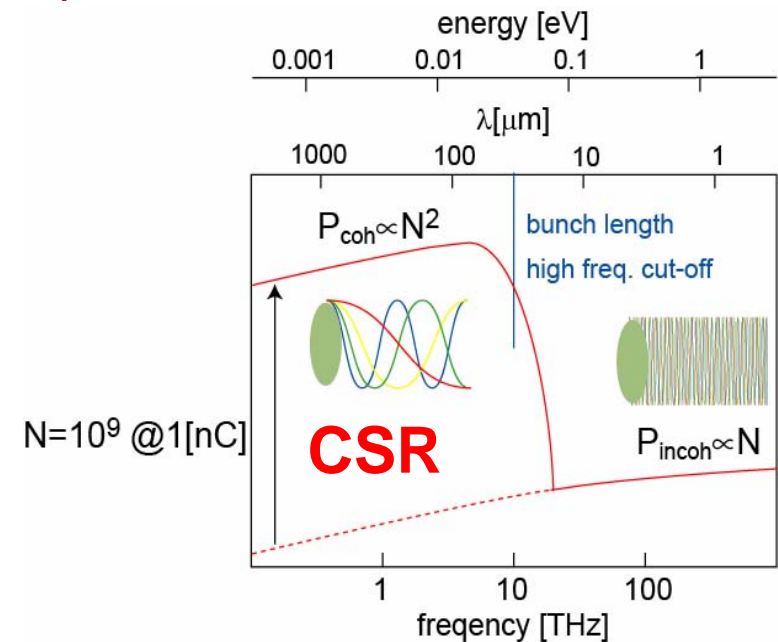
# CSR from relativistic e-bunch

:bunch length

- 1) wavelength < bunch length ..... incoherent radiation
- 2) wavelength > bunch length .... coherent radiation



## Spectrum



Ultra short electron bunch is necessary for coherent THz radiation.

Bunch length = **high frequency** cut-off

**HIGH POWER and STRONG E-FIELD**

# Temperature jump:

## vibrational excitation through electron-phonon coupling

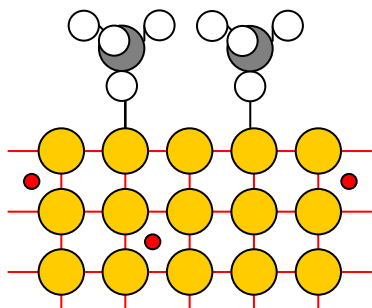
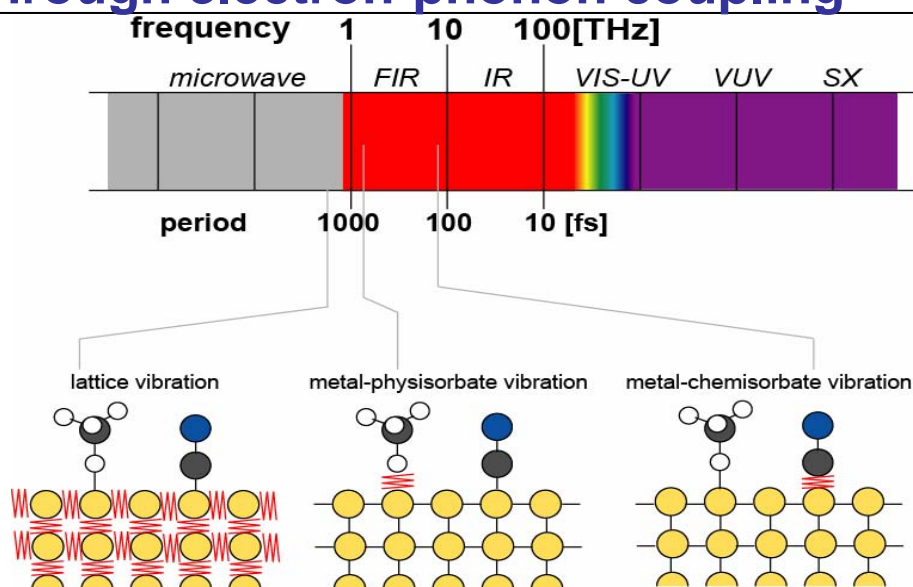
### Temperature jump

via

Electron-hole pair excitation,  
Lattice vibration excitation,

....

**required power: ~1-10 mJ/pulse**



fs laser: hot electron problem

THz: NO hot electron

Temperature jump ensues the motion of adsorbate and stimulates surface chemical reactions.

# Temperature jump: vibrational excitation

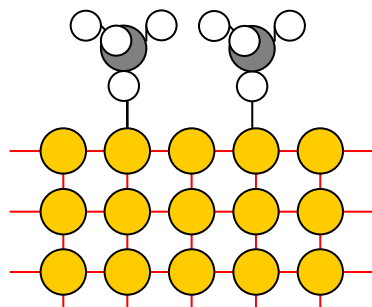
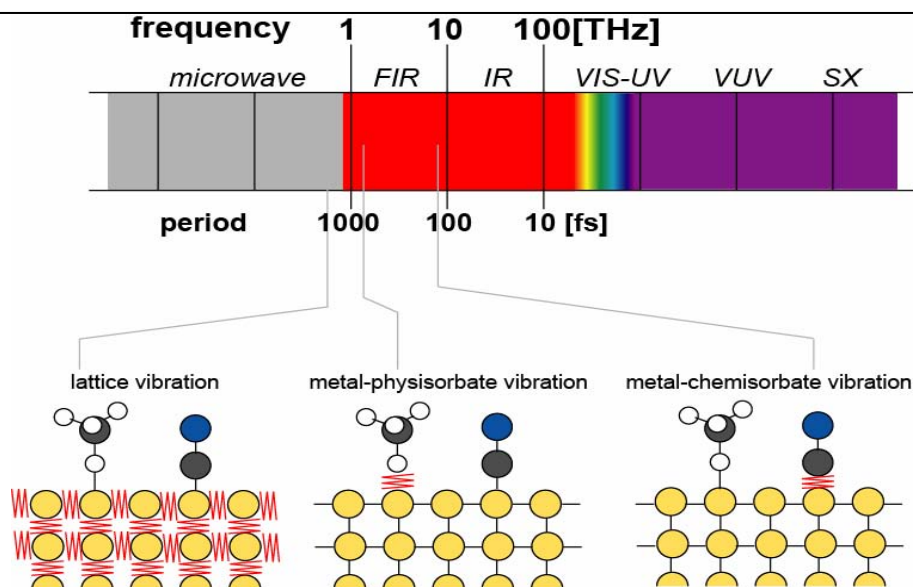
## Temperature jump

via

Electron-hole pair excitation,  
Lattice vibration excitation,

....

**required power: ~1-10 mJ/pulse**

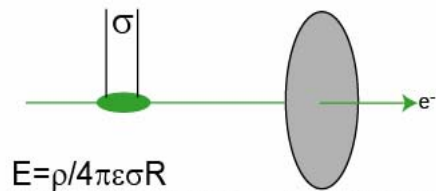


fs laser: hot electron problem

THz: NO hot electron

Temperature jump ensues the motion of adsorbate and stimulates surface chemical reactions.

# E-field and surface chemistry

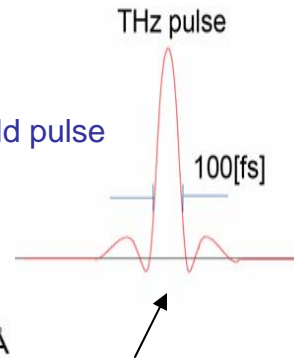


$$E = \rho / 4\pi\epsilon\sigma R$$

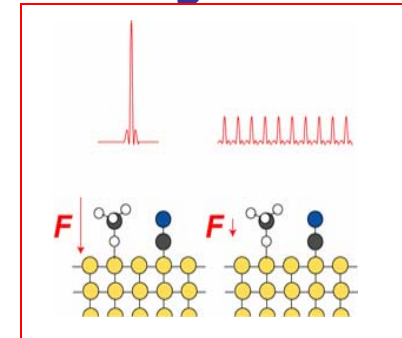
$$= 1\text{nC} / (4 \cdot 3.14 \cdot 20\mu \cdot 100\mu \cdot 8.854\text{pF/m})$$

$$= 4.5\text{GV/m} = \underline{0.45 \text{ V/\AA}}$$

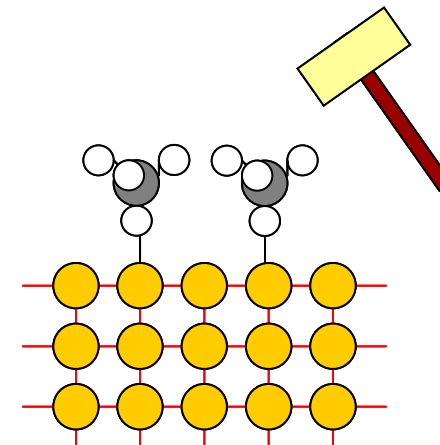
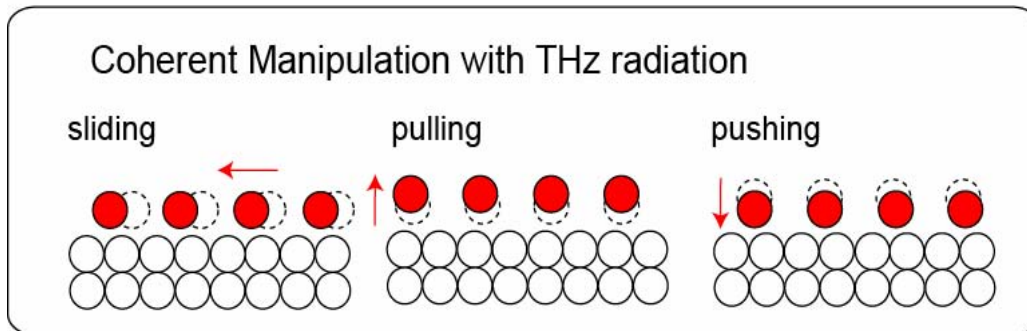
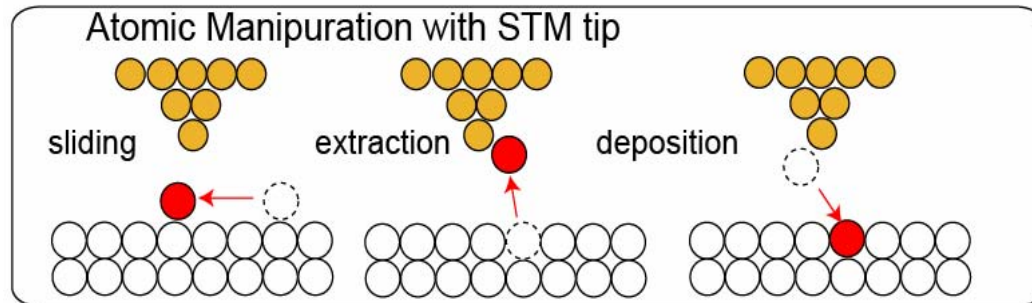
strong electric field pulse



$\sim 0.1\text{-}0.3 \text{ V/\AA}$



Pulse width  $\sim$  time scale of molecular vibration

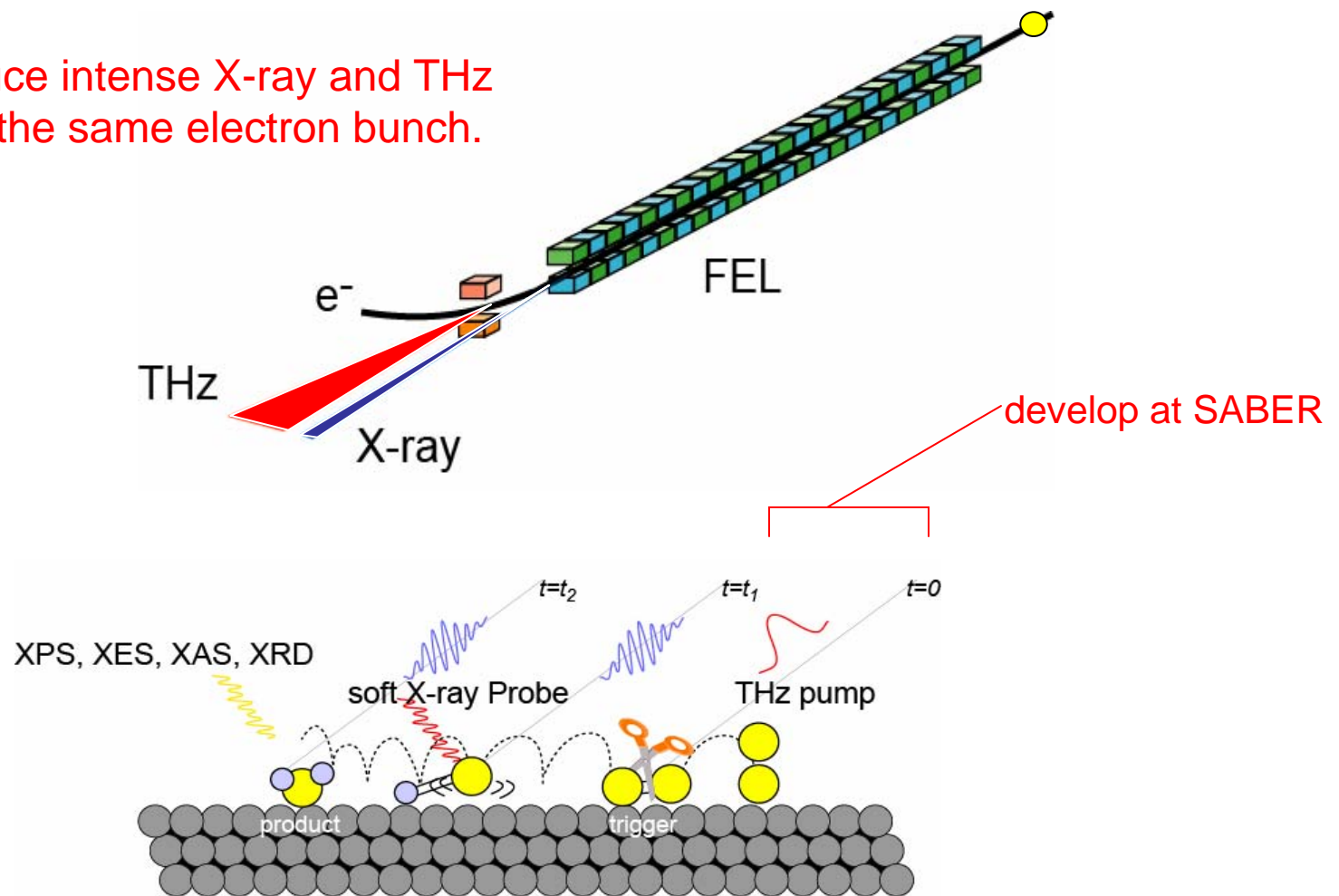


THz electric field  $\sim$  Coulomb force between  $e^-$  and the nuclei  
manipulation of molecule, coherent control molecular motion



# How to probe THz induced process

FEL can produce intense X-ray and THz radiation from the same electron bunch.



on-axis radiation, soft X-ray, hard X-ray, off-axis radiation: THz  
**Pump:** THz, **Probe:** XPS, XES, XAS, XRD, IR

# Summary THz generation

- THz region = far IR  $\sim kT$   
lattice vibration, adsorbate-substrate vibration
- coherent radiation  $\sim 10^9$  \* incoherent radiation
- short electron bunch = high cut-off frequency
- coherent broad band = electric field pulse
- coherent atom manipulation on surfaces

Bunch length:  $\sim 100\text{fs}$ , Charge:  $\sim \text{nC}$



# Experimental setup

